

RF EXPOSURE EVALUATION DOCUMENT

For SPEN WPT Charging

- Applicant : SAMSUNG ELECTRONICS CO., LTD. 129 SAMSUNG-RO, YEONGTONG-GU, SUWON-SI, GYEONGGI-DO, 16677, KOREA
 - Model : SM-X710
 - FCC ID : A3LSMX710
- EUT Description : Tablet with BT, DTS/UNII a/b/g/n/ac/ax and WPT

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Prepared by:

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1. TEST PROCEDURE

Per FCC Guidance, WPT function was evaluated for portable exposure condition.

2. FACILITIES AND ACCREDITATION

The test sites and measurement facilities used to collect data are located at 218 Maeyeongro, Yeongtong-gu, Suwon-si, Gyeonggi-do, 16675, Korea. Line conducted emissions are measured only at the 218 address. The following table identifies which facilities were utilized for radiated emission measurements documented in this report. Specific facilities are also identified in the test results sections.

218 Maeyeong-ro	
Shield Room	

UL Korea, Ltd. is accredited by IAS, Laboratory Code TL-637. The full scope of accreditation can be viewed at https://www.iasonline.org/wp-content/uploads/2017/05/TL-637-cert-New.pdf.

3. INFORMATION OF EQUIPMENT UNDER TEST

Information					
Operating frequency [MHz]	0.531				
Maximum output power [mW]	50				
Charging type	Inductive wireless power transfer				
Operating duty factor	0.5 (15min / 30min)				

4. TEST EQUIPMENT

Test equipment (Measurement probe)					
Description Manufacturer		Model	S/N	Cal due.	
E-H Field Analyzer	Narda	EHP-200AC	170WX91008	8-23-2023	

5. MEASUREMENT RESULT

Spen WPT	Distance			H-field me [A	asuremen /m]	t	
Coil Location	Diotailoo	Rear	Front	Тор	Left	Right	Bottom
Location.1	0cm	0.5282	0.0835	0.0721	0.0152	0.1612	0.0152
Location.2	0cm	0.4511	0.0712	0.0152	0.0152	0.1542	0.0152

5.1. H-field measurement results of EUT's 6 sides

(0mm distance means that the probe's surface are touched at DUT's surface.)

5.2. H-field measurement results for 0cm to 10cm at Rear side.

	Location.1		Loca		
Distance [cm]	H-field meas. [A/m]	H-field x (duty factor) [A/m]	H-field meas. [A/m]	H-field x (duty factor) [A/m]	FCC Limit [A/m]
0	0.5282	0.2641	0.4511	0.2256	
1	0.2588	0.1294	0.2144	0.1072	
2	0.1295	0.0648	0.1088	0.0544	
3	0.0810	0.0405	0.0542	0.0271	
4	0.0562	0.0281	0.0282	0.0141	
5	0.0282	0.0141	0.0232	0.0116	1.63
6	0.0232	0.0116	0.0172	0.0086	
7	0.0172	0.0086	0.0152	0.0076	
8	0.0153	0.0077	0.0152	0.0076	
9	0.0152	0.0076	0.0152	0.0076	
10	0.0152	0.0076	0.0152	0.0076	

(Distance means that the probe's surface are touched at DUT's surface.)

5.3. Corrected H-field measurement

Operating duty factor is based on Averaging time of §1.1310 table 1.

- Location.1 : 5282 A/m * 0.5 = 0.2641 A/m
- Location.2 : 4511 A/m * 0.5 = 0.2256 A/m